

JS401-300 Spin Coater, floor type

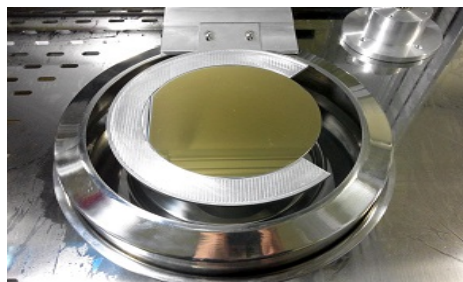
300 mm Spin Coater

The JS401-300 of 12" wafer spincoaters is designed for versatility, ease of use and safety in a variety of manual and automated research and development processes. The spincoaters are ideal for processes such as the coating and developing of silicon wafers, glasses, large photomasks, reticles.

- Combined with a dispensing nozzle for PR coating
- Easy to use
- Repeatable performance
- Flexibility for programing
- Optional auto swing arm dispensing system
- Wafer alignment tool

Specification

Programmable 20 steps, 20 recipes stored
PLC and LCD Touch panel display
Accuracy ± 1 RPM
Max RPM: 4,000
Acceleration: 10,000RPM/sec.
Acceleration and deceleration settable by 0.1 sec.
SUS304 body and bowl
for easy cleaning and chemical resistance
Manual wafer alignment tool attached
Drain port
Clear glass door for observation
Max 300mm diameter wafer
Standard dry vacuum pump: 100 liter/ min, 0.5 ATM
Standard sample chuck
Dimension 1000W x 800D x 1800H mm
220VAC, 60Hz, 15 amp
Weight: 225 Kg



JAESUNG JS401 FLOOR TYPE SPIN COATING SYSTEM

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